

Title (en)  
COMPOSITION AND METHOD FOR REDUCING FOULING IN PROCESS EQUIPMENT USED FOR MANUFACTURING AROMATIC MATERIALS

Title (de)  
ZUSAMMENSETZUNG UND METHODE ZUR HEMMUNG DER BELAGBILDUNG IN PROZESSANLAGEN, DIE FÜR DIE HERSTELLUNG VON AROMATISCHEN STOFFEN VERWENDET WERDEN

Title (fr)  
COMPOSITION ET PROCEDE DE REDUCTION D'ENCRASSEMENT DANS UN EQUIPEMENT UTILISE POUR LA FABRICATION DE MATIERES AROMATIQUES

Publication  
**EP 0971871 A1 20000119 (EN)**

Application  
**EP 98911611 A 19980312**

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Abstract (en)  
[origin: WO9843937A1] Methods for reducing the fouling of process equipment used in the manufacture of aromatic compounds such as dimethyl-2,6-naphthalenedicarboxylate are disclosed. The methods require treating manufacturing process streams with a metal complexing agent. Novel compositions useful in the manufacture of aromatic materials such as dimethyl-2,6-naphthalenedicarboxylate also are disclosed.

IPC 1-7  
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IPC 8 full level  
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